



Atty. Dkt. No. 035905-0118

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Igor G. KOUZNETSOV et al.

Title: TWO MASK FLOATING GATE EEPROM AND  
METHOD OF MAKING

Appl. No.: 10/066,376

Filing Date: 02/05/2002

Examiner: Long Pham

Art Unit: 2814

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**RESPONSE TO RESTRICTION REQUIREMENT**

Mail Stop NON-FEE AMENDMENT  
Commissioner for Patents  
PO Box 1450  
Alexandria, Virginia 22313-1450

Sir:

In response to the Restriction Requirement dated November 13, 2003, Applicants hereby elect, with traverse, claims of Group II, claims 1-17, drawn to a semiconductor device. The traverse is on the ground that Applicants request rejoinder of method claims of equal or narrower scope to any allowed device claim, as provided in MPEP § 821.04. Applicants, of course, reserve the right to file a divisional application covering the subject matter of the non-elected claims. Receipt of the initial Office Action on the merits is awaited.

Respectfully submitted,

Date 12/12/03

By Lev Radomsky

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